

# Fraunhofer IZM - Micro Materials Center

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## Thermal Management and Thermo Mechanical Reliability

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Olaf Wittler



Micro Materials Center  
Berlin and Chemnitz  
Head: Prof. B. Michel

# Micro Materials Center

Head: Prof. Bernd Michel

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## Micro Materials Center Berlin

- 4 Research Groups
  - Prof. Bernd Michel
  - Dr. Ole Hölck / Dipl.-Ing. Daniel May
  - Dr. Hans Walter
  - Dr. Olaf Wittler
- 1 PhD Group: Prof. Bernhard Wunderle
- Lab Locations
  - Berlin-Wedding
  - Berlin-Adlershof

## Micro Materials Center Chemnitz → Fraunhofer Einrichtung ENAS

- 3 Research Groups

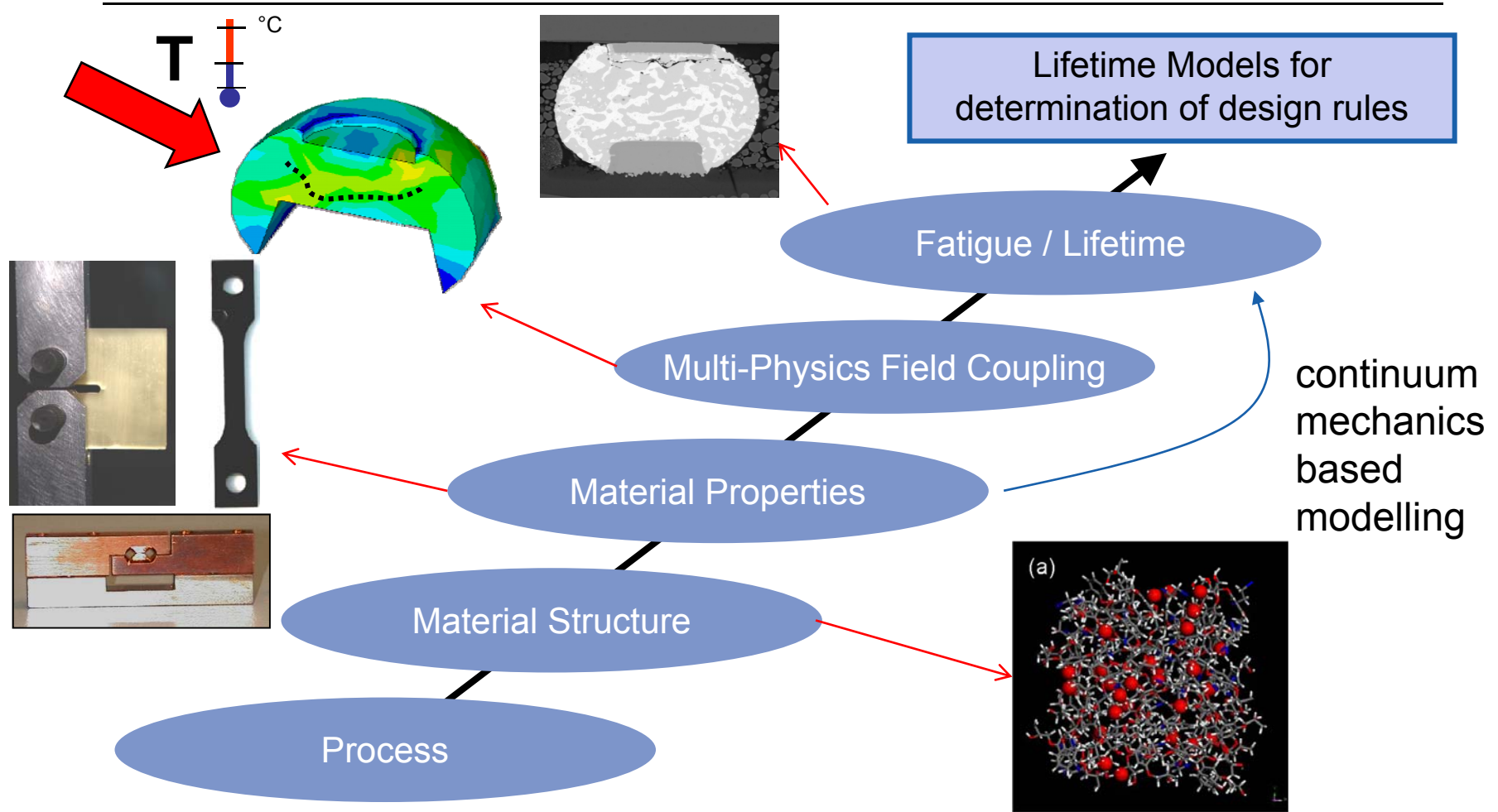
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Berlin and Chemnitz  
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# Lifetime Models and Design for Reliability



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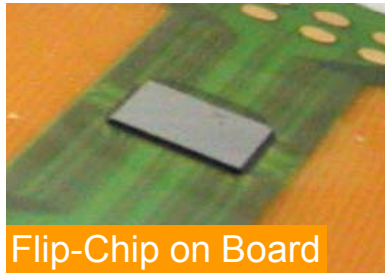
# IZM Program

## Micro Reliability & Lifetime Estimation



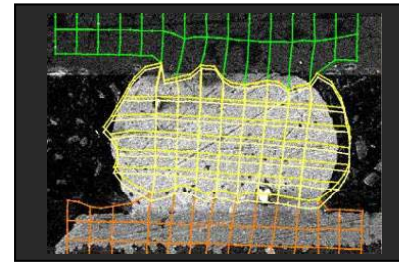
Fraunhofer Institut Zuverlässigkeit und Mikrointegration

### Lifetime Prediction for Advanced Packaging Solutions

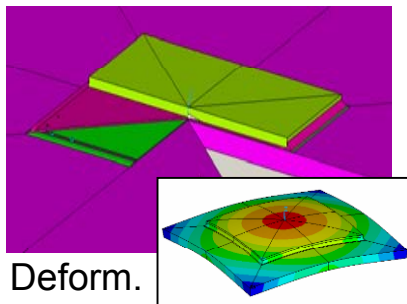


Flip-Chip on Board

Thermo-mechanical reliability testing

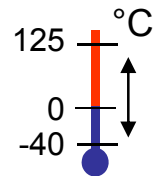


μ-Deformation measurements

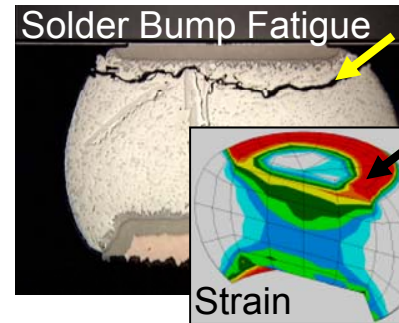
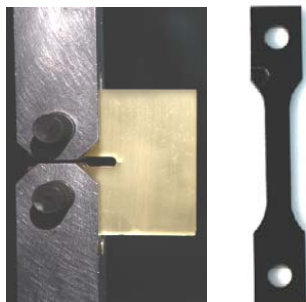


Deform.

Parametric Finite Element simulation



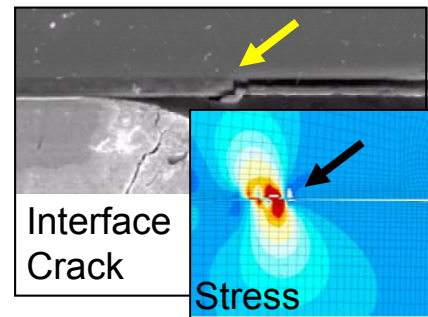
Material characterisation



Solder Bump Fatigue

Strain

Failure Analysis & Mechanisms



Interface Crack

Stress

Lifetime prediction & theory

$$\bar{N}_f = c_1 (\bar{\epsilon}^{cr})^{c_2}$$

Contact: Prof. Dr. B. Michel, Mail to: [bernd.michel@izm.fraunhofer.de](mailto:bernd.michel@izm.fraunhofer.de)

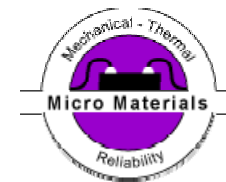
Dep. Mechanical Reliability and Micro Materials, Head: Prof. Dr. B. Michel, Fraunhofer IZM, Berlin, Germany

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# Material Characterisation

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Berlin and Chemnitz  
Head: Prof. B. Michel

# Methods/Equipment for Material Characterisation - Mechanical Testing Lab



Zwick 1446

- CTE Measurement with TMA
- Time, Temperature and Humidity dependent Properties
  - Elasticity
  - Viscoelasticity
  - Creep



DMA 242

- Fatigue behaviour by dynamic measurements
- Nano-Indentation

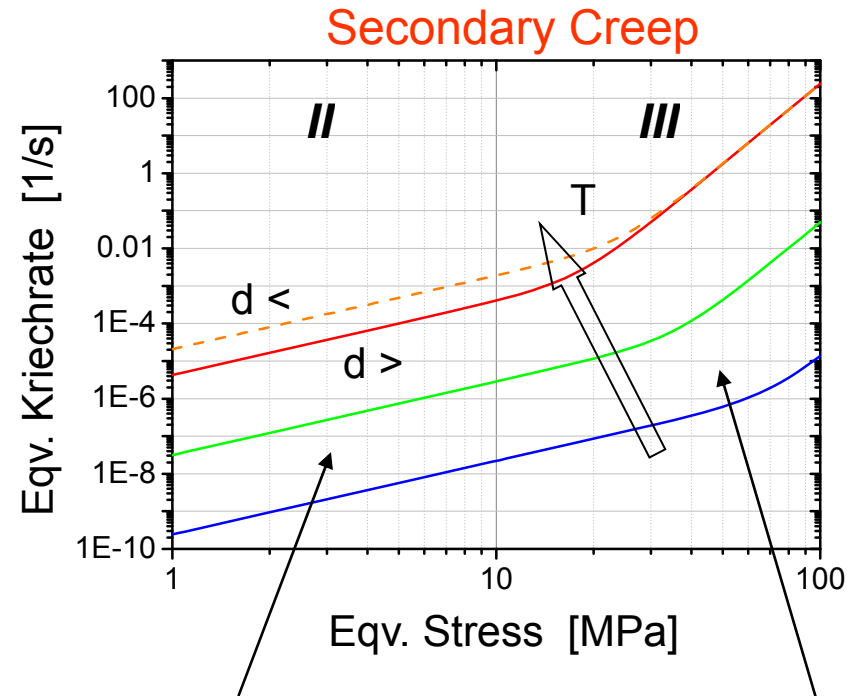
Tytron 250



TMA 202



# Creep Law (Eut. SnPb), Viscoplasticity



Activation Energy

Grain size

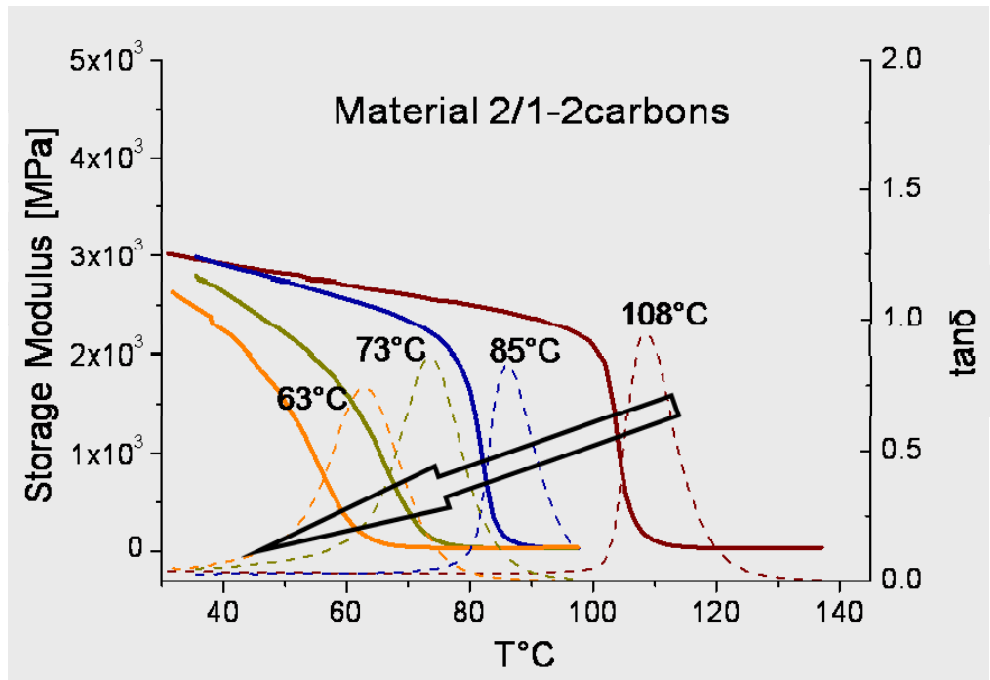
Grain Boundary Sliding  
Stress <

Matrix Deformation  
Stress >

Absolute temperature

$$\dot{\epsilon} = \frac{1}{\sqrt{3}} \frac{A_{II}}{T} \frac{1}{d^p} \left( \frac{\bar{\sigma}}{\sqrt{3}} \right)^{n_{II}} \exp \left\{ -\frac{Q_{II}}{kT} \right\} + \frac{1}{\sqrt{3}} \frac{A_{III}}{T} \left( \frac{\bar{\sigma}}{\sqrt{3}} \right)^{n_{III}} \exp \left\{ -\frac{Q_{III}}{kT} \right\}$$

# Moisture Temperature Dependent Material Characterisation



- dry
- 65°C/65RH, 2.90wt%
- 85°C/85RH, 4.78wt%
- 98°C/100RH, 7.77wt%



Examples for test specimen

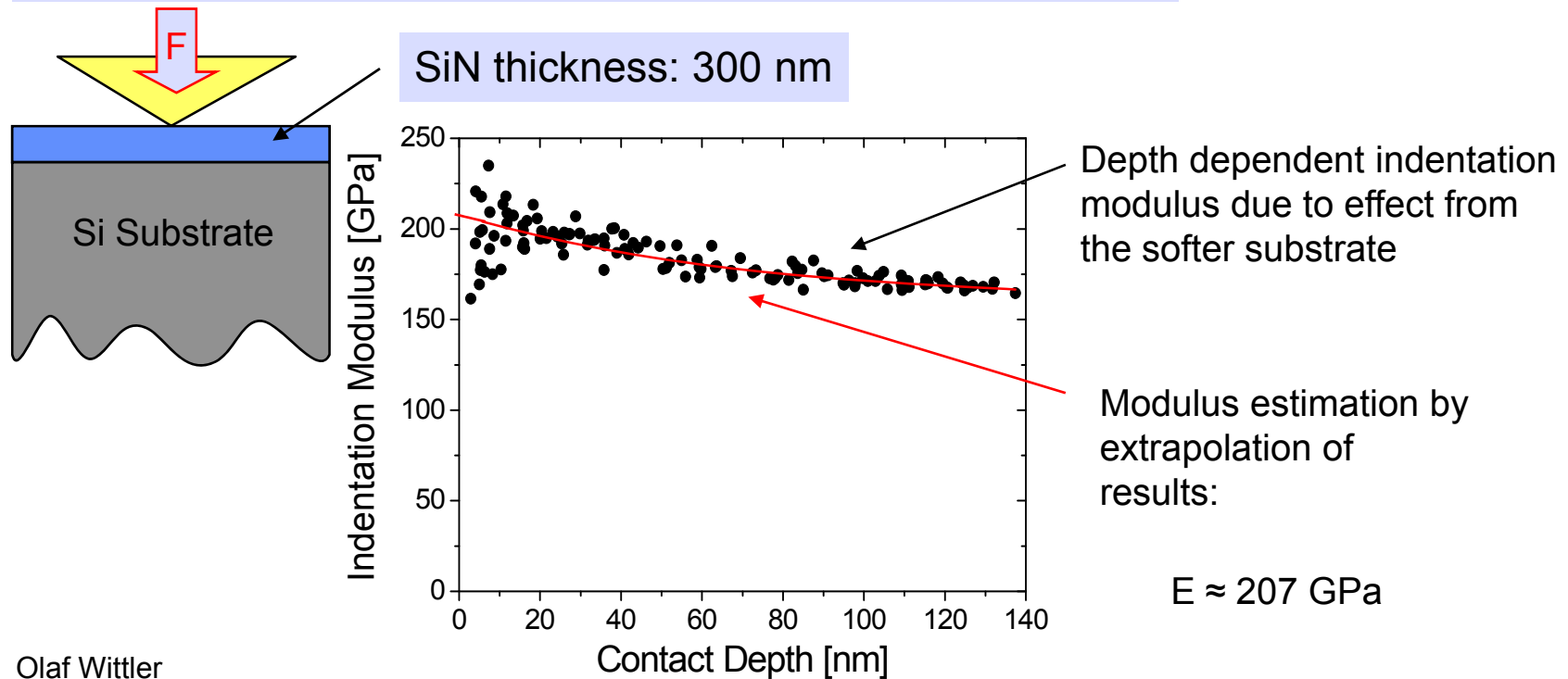
→ Viscoelastic Material Data for Polymers

E. Dermitzaki, H. Walter



# Material Characterisation by Nanoindentation

Example: Thin film characterisation for MEMS applications  
Material: SiN



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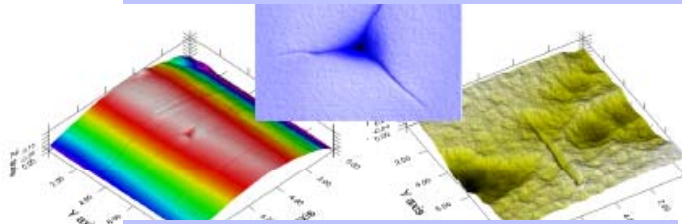
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# Measurement System: Hysitron Triboindenter

Options available at IZM

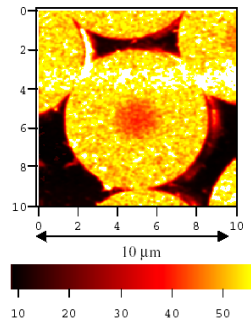
## Classical Nanoindentation

### In-situ scanning of indents



### Scratch and wear testing

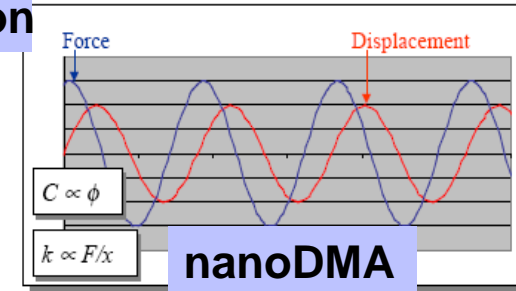
Storage Modulus, GPa



### Modulus mapping

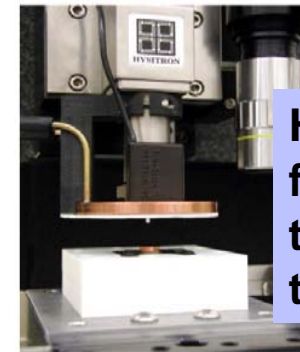


Triboindenter in acoustic/thermal enclosure



$$E' = \frac{\gamma_s \sqrt{\pi}}{\sqrt{A_c}} \quad E'' = \frac{\omega C_s \sqrt{\pi}}{2\sqrt{A_c}}$$

Analysis of sinusoidal force/displacement data.

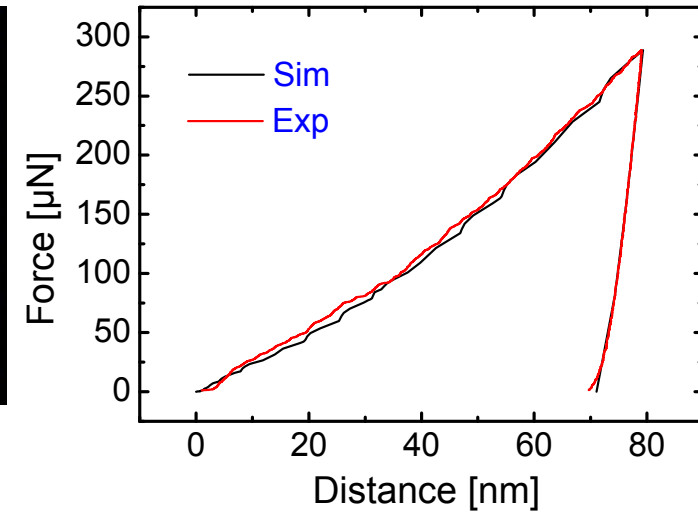
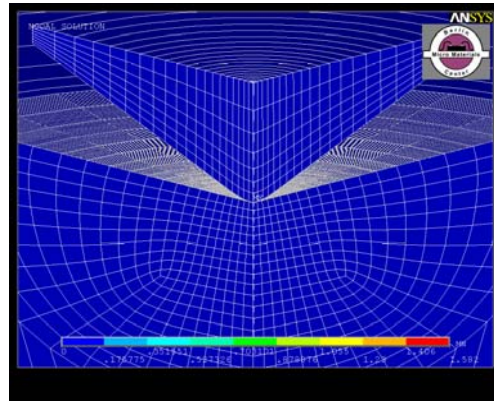
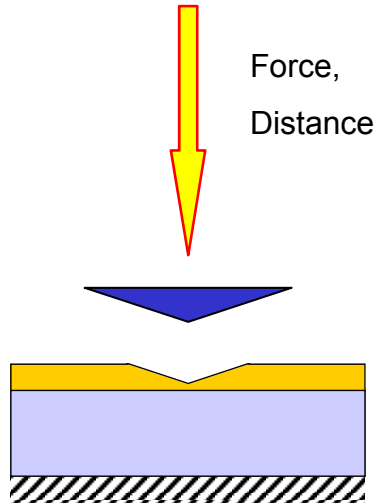


### Heating stage for temperatures up to 200°C

Image Source: Hysitron Product Information

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# Material Characterisation in the Nano-Region

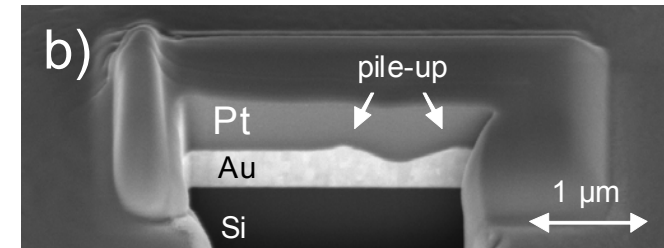
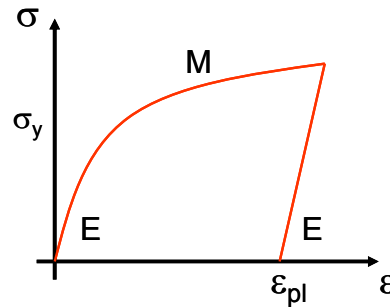


Experiment

Simulation

until Agreement reached

→ Determination of Parameters only in Coupling to Simulation possible



B. Wunderle, R. Mrossko, E. Kaulfersch, O. Wittler, P. Ramm, B. Michel and H. Reichl.  
MRS Fall Meeting, Boston, USA, Nov. 2006

# Main Relevant Properties

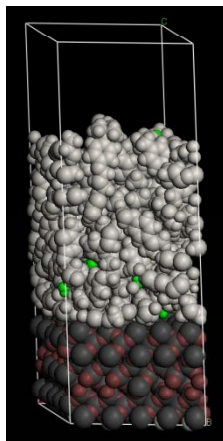
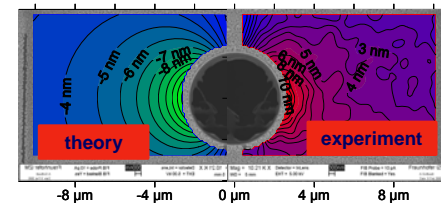
## Deformation Behaviour

Nanoindentation / nanoDMA



## Residual Stresses

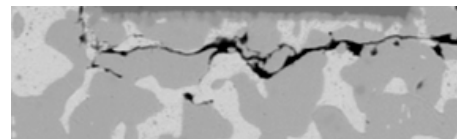
nanoRaman / fibDAC / ...



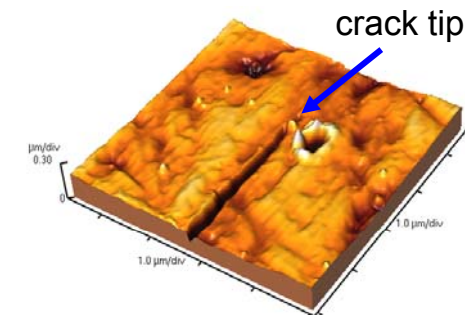
## Interfacial Fracture Toughness and Moisture

- MC
- H<sub>2</sub>O
- SiO<sub>2</sub>

## Metal Fatigue



## Fracture Toughness (Cohesive Strength)



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# Methods Overview – Interfacial Fracture Toughness

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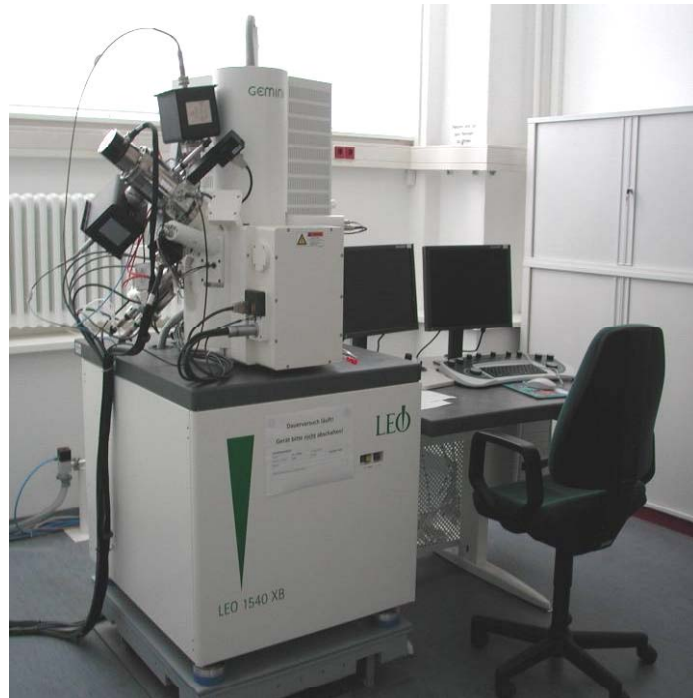
Methods for interfacial fracture toughness of thin films

- Scratch Testing
  - Only qualitative in nature
  - + No sample preparation
- Modified Edge Lift Off Technique
  - + Quantitative  $G_c$  determination
  - Measurements only at low temperatures
  - + large quantitative numbers to be measurable
- Four-Point-Bending
  - + Quantitative  $G_c$  determination
  - + Temperature dependent measurement possible
  - Specimen preparation

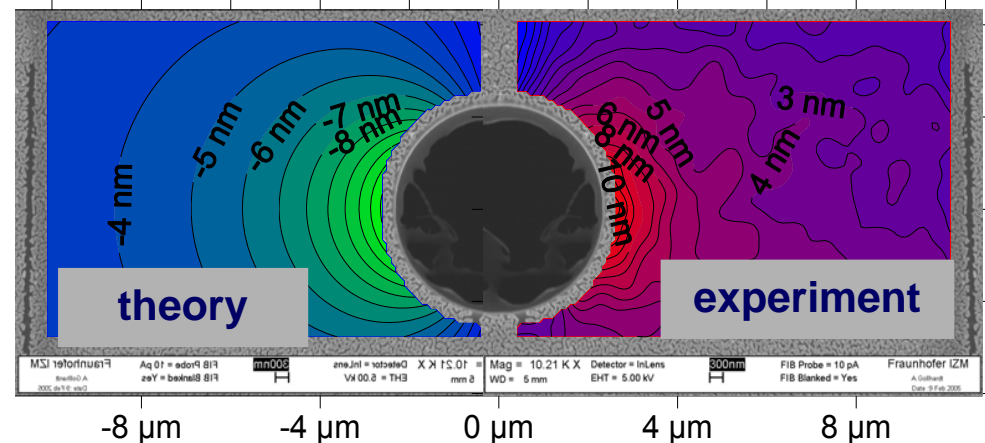
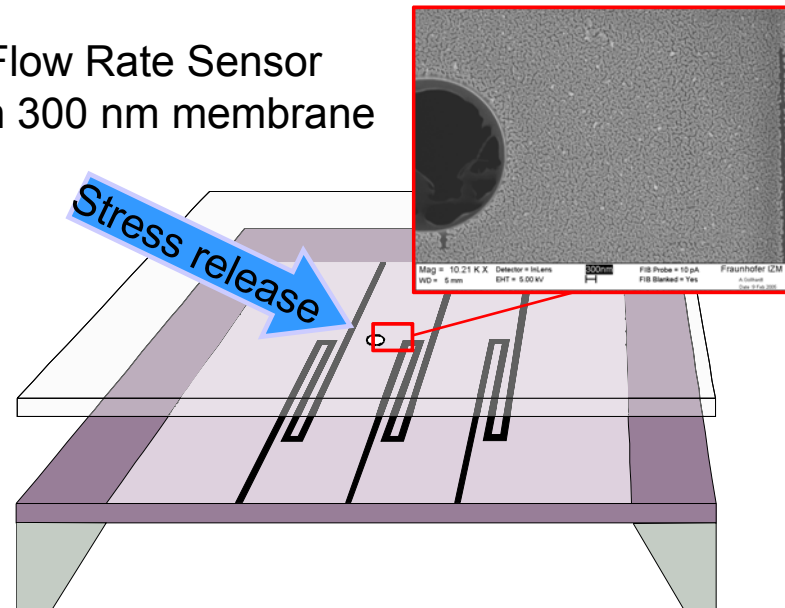
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# fibDAC – Residual stresses at sub- $\mu\text{m}$ Scale



Flow Rate Sensor  
with 300 nm membrane



- ☞ Stress release by ion milling in focused ion beam equipment
- ☞ ***Stress determination from measured deformation field (right)***
- ☞ Material data by nano-indentation

D. Vogel, N. Sabate, J. Keller, B. Michel,

**Fraunhofer Prize 2005**

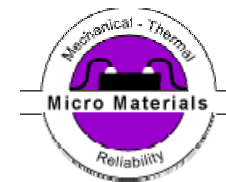
# Methoden Übersicht – Residual Stress Testing

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- Wafer Curvature
- Röntgenbeugung (Winkel- / Energiedispersiv)
- fibDAC
- Ramanspektroskopie
- EBSD (Elektron Back Scatter Diffractometry)

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# Modelling and Reliability Estimation

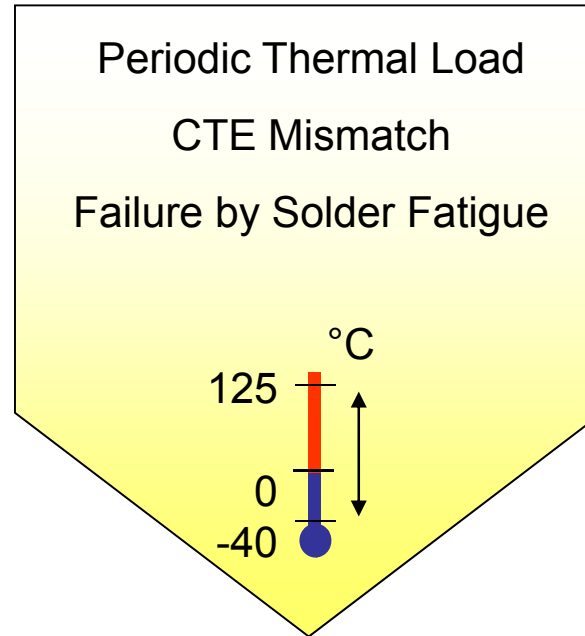
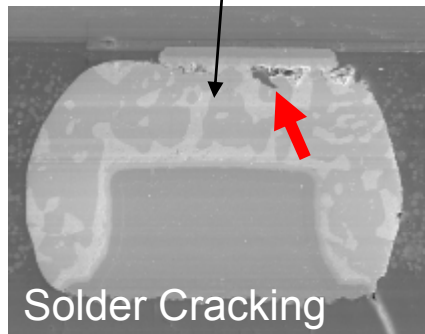
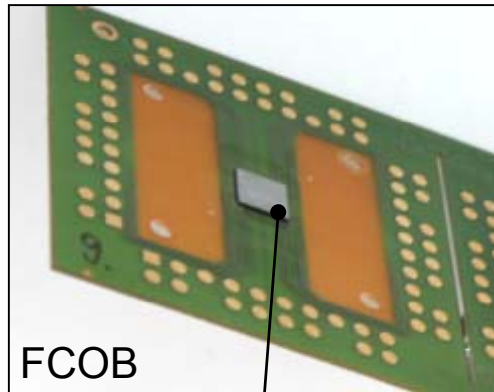
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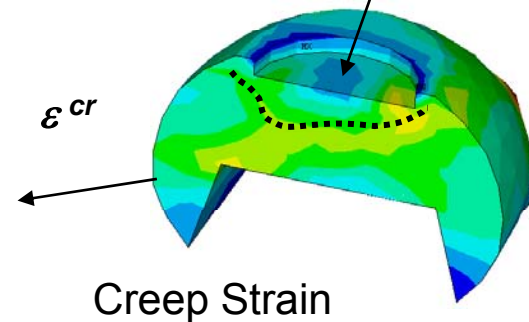
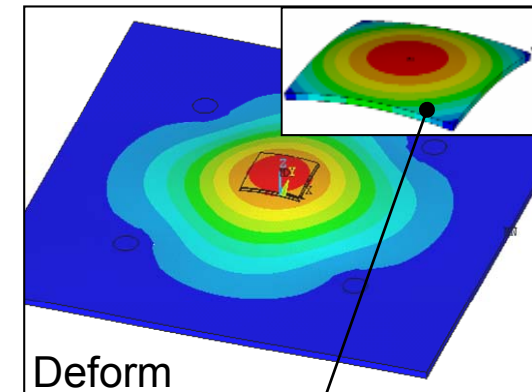


# Solder Fatigue in Experiment and Simulation

Test - Specimen: in  
**Experiment...**



**...and Simulation**  
(Boundary Conditons)



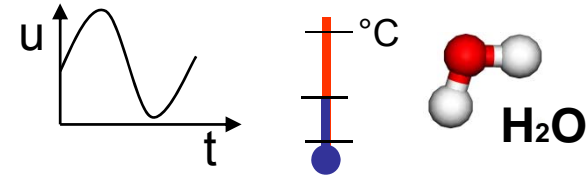
Reliability via  
Coffin Manson

$N_f$

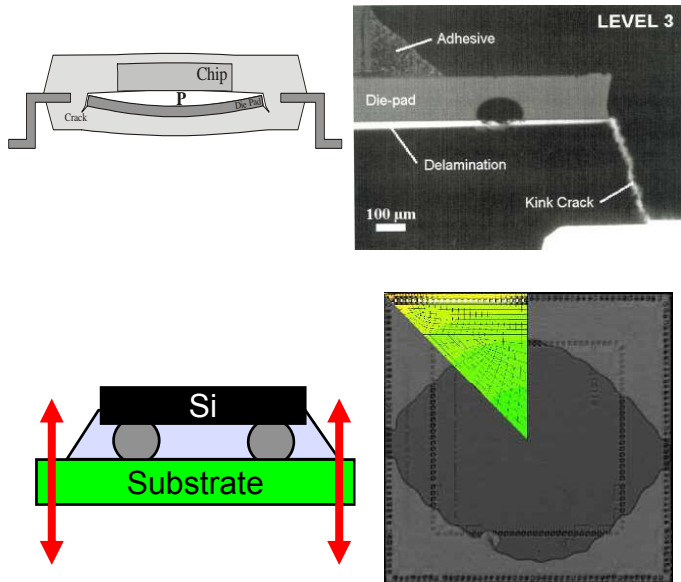
$$\bar{N}_f = c_1 (\bar{\epsilon}^{cr})^{c_2}$$

- $c_1, c_2 = f(\text{Mat.}, \text{Cycle})$
- Char. Curve for Material at  $T(t)$

# Load Combination



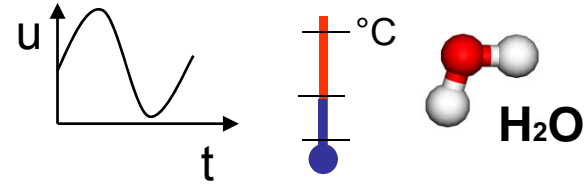
## Example failure mechanisms



- Moisture + Temperature
  - Accelerated moisture transport
  - Popcorning
- Moisture/Temperature + Vibration
  - Reduction of interfacial adhesion
  - Mechanical interface load
- Temperature Cycling + Vibration
  - Initial degradation by Temperature cycling
  - Instable crack growth during vibration

The combination of loads can be more critical than the single loads.  
→ Combined testing

# Test Set-up



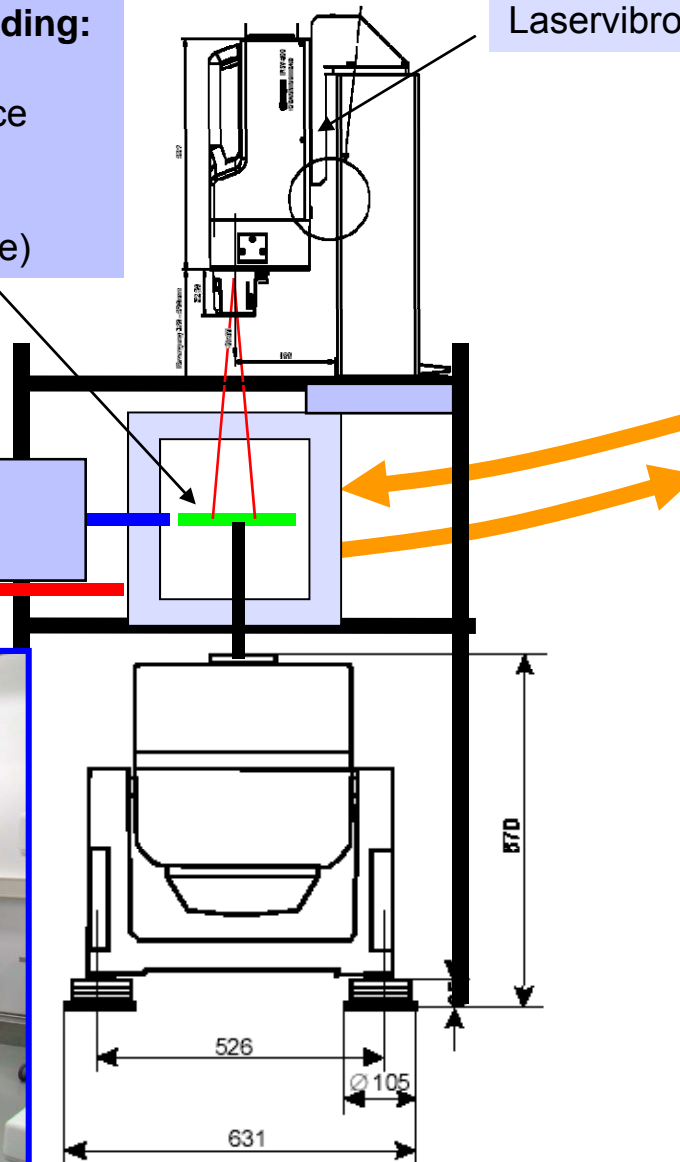
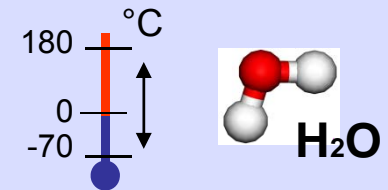
## Electrical In-Situ Monitoring/Loading:

- up to 256-Channels
- Resistance, Capacity, Inductance
- Temperature, Acceleration
- Digital I/O
- Active Power Control (Real-Time)

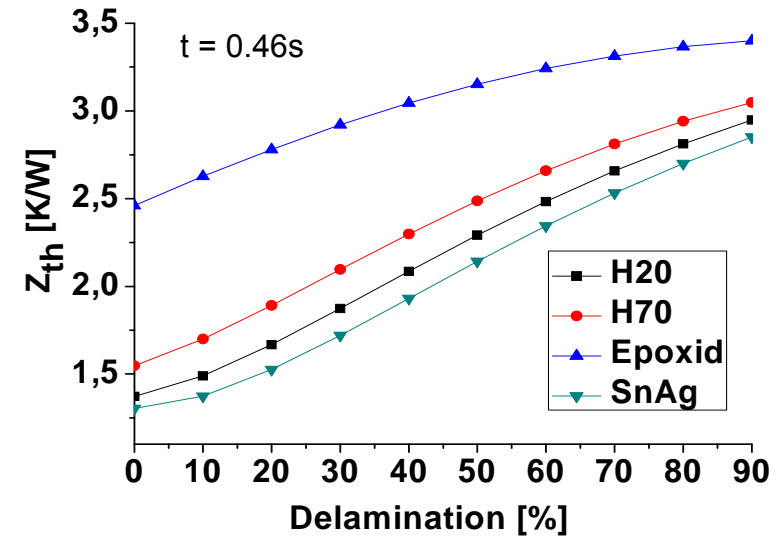
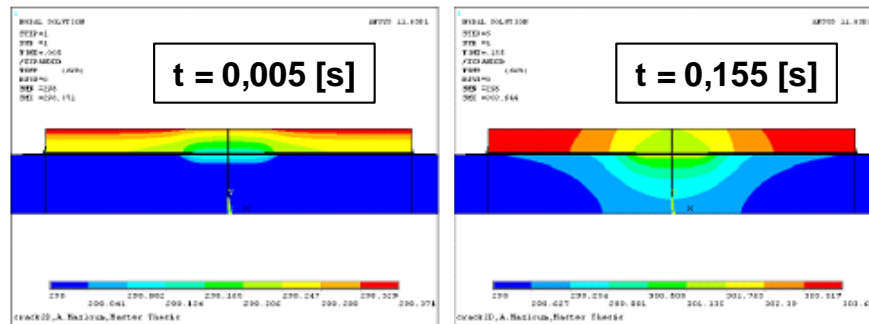
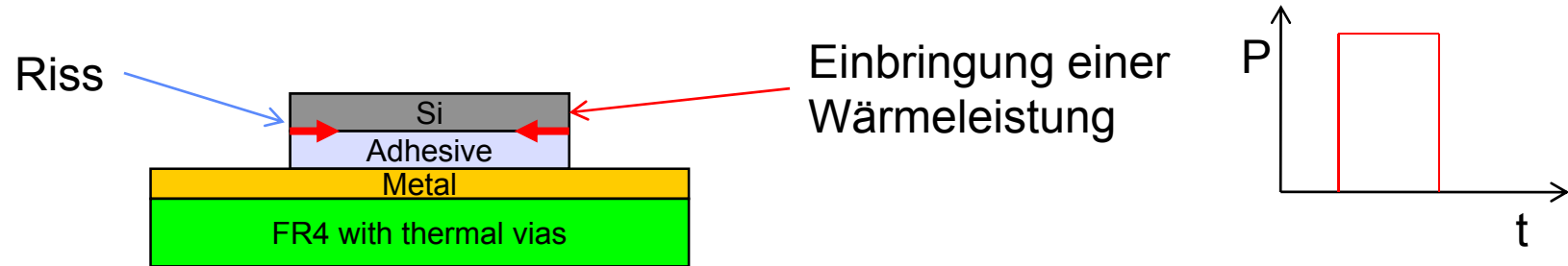
## Laservibrometer (IR-Camera)

Optics (OCT, DAC)

Climate Chamber  
T, RH



# In-Situ „Health Monitoring“ für Die Attach Verbindungen



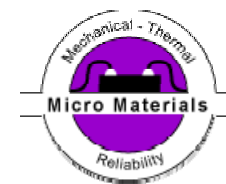
Fast lineare Relation von Risslänge und transientem Thermischem Widerstand  $Z_{th}$

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# Thermal Modelling and Characterisation

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Micro Materials Center  
Berlin and Chemnitz  
Head: Prof. B. Michel

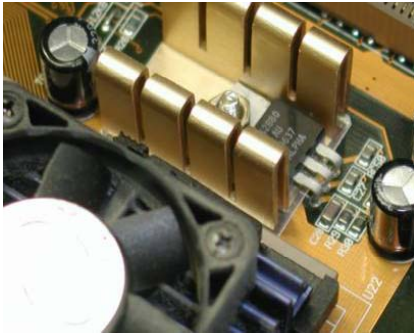


# IZM Program

## Thermal Management



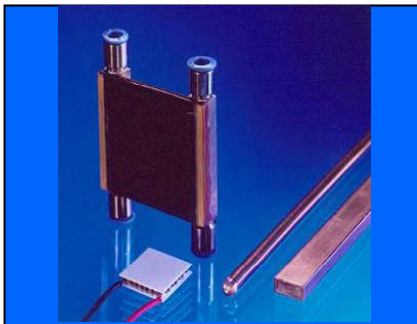
Fraunhofer  
Institut  
Zuverlässigkeit und  
Mikrointegration



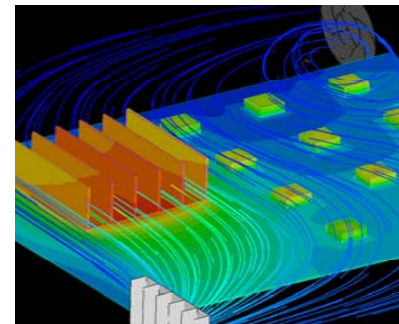
Reliability & cost-  
optimised design for  
cooling systems



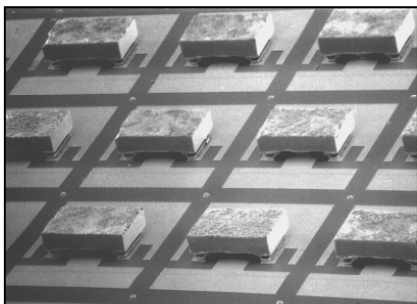
Material  
characterisation



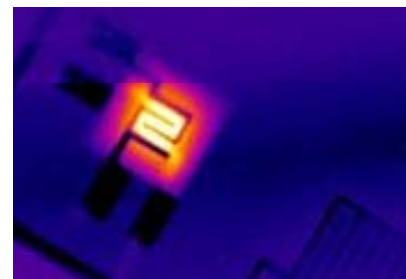
Implementation of  
advanced cooling  
concepts



Virtual prototyping

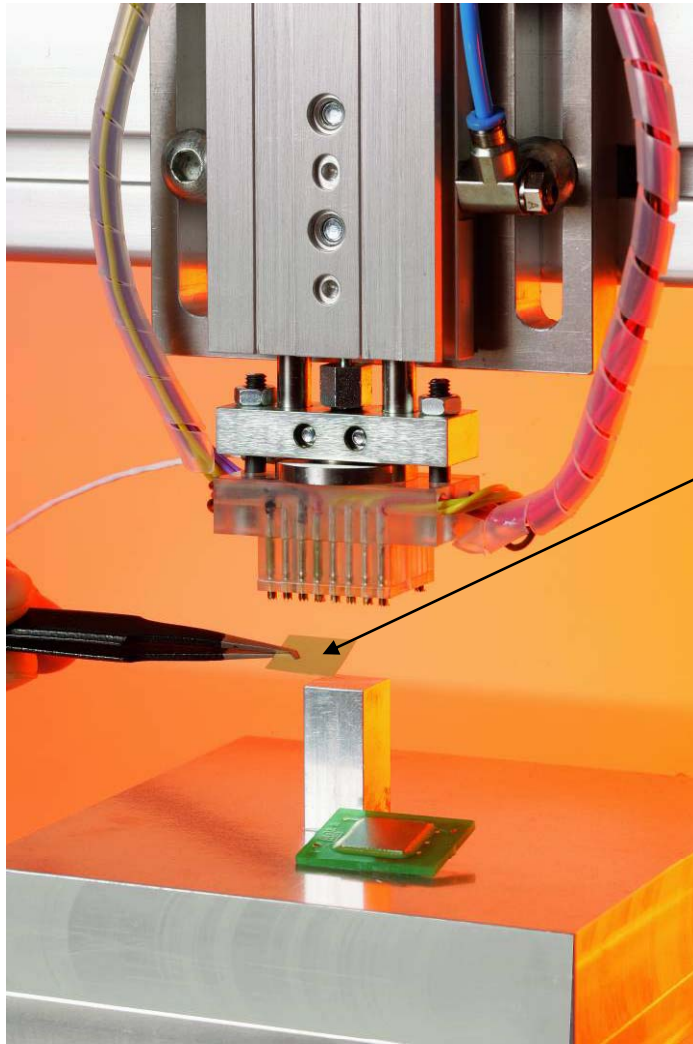


Technological support  
and processes:  
from *hand-held* up to  
*high-performance*



Verification and  
testing

# Thermal Characterization of Materials

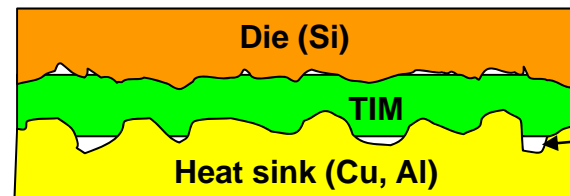


$$\vec{j} = -\lambda \text{ grad } T$$



Thermal Conductivity

Probe (TIM)



Void

At IZM developed method  
to characterize all classes of TIMs incl. interface  
resistance under real application condition  
(pressure, thickness, temperature)

R. Schacht, E. Auerswald, J.P. Sommer, B. Wunderle, B. Michel and Reichl.  
ESTC 2006, Sep 5-7, 2006, Dresden, Germany

B. Wunderle, R. Schacht Nov. 2007

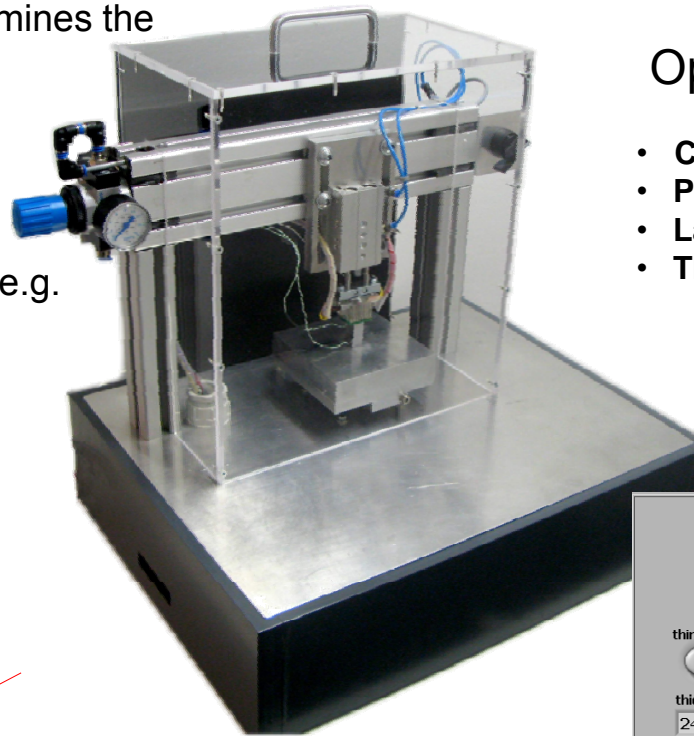
# Characterization of Thermal Interface Materials (TIM)

New measurement method determines the

- **Effective thermal resistance**
- **bulk conductivity**
- **interface resistance**

of all commercially available TIM e.g.

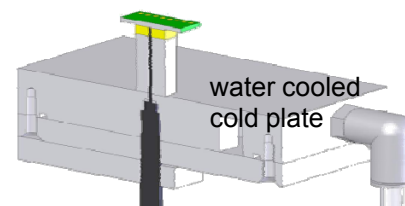
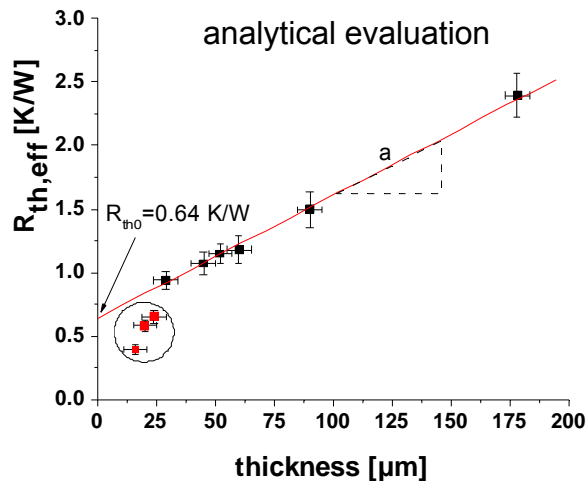
- **Greases**
- **Elastomeric Pads**
- **Phase Change Materials**
- **Adhesives**
- **Solder and etc**



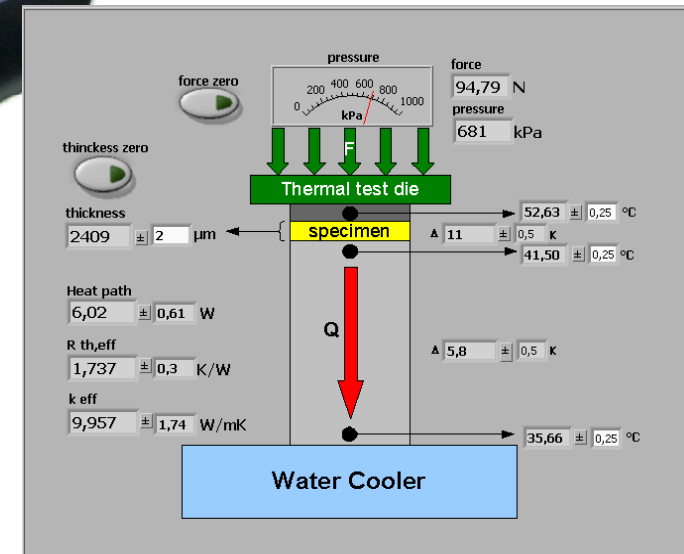
Operational conditions:

- **Chip temperature:  $T_j = (50...130)^\circ\text{C}$**
- **Pressure:  $p = (0,1...1) \text{ MPa}$**
- **Layer thickness:  $d = (5...5000)\mu\text{m}$**
- **Thermal conductivity:  $\lambda_{\text{bulk}} < 10 \text{ W/m K}$**

Computer controlled measurement



Thickness determination by integrated displacement transducer (LVDT)



Abo Ras, May, Schacht, Wunderle

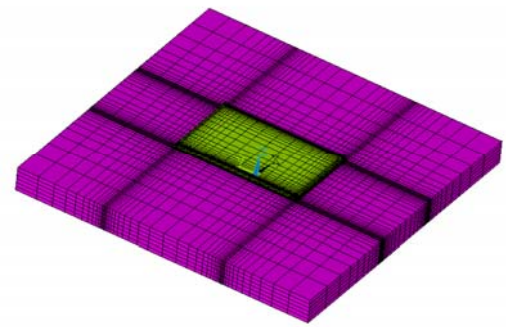
Thermo-Electrical Testing



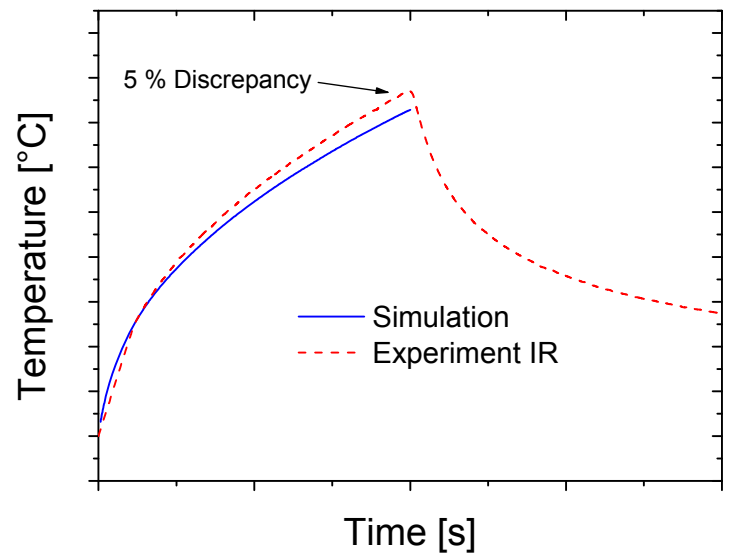
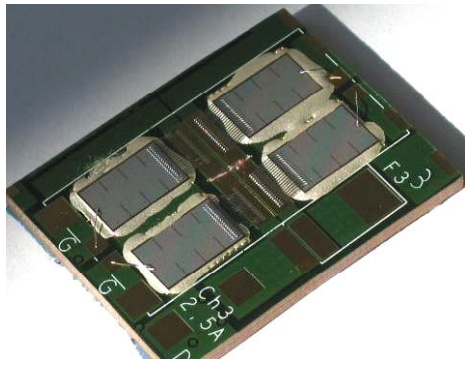
# Measurement & Simulation - Transient Thermal Load

COB on LP

Model



Experiment



## Goal

- Design optimization

## Result

- Transient load is important, → more Cu necessary !!

**Important criterions:**  
Diffusivity, Geometry, Voids,  
Eff. Material data, hotspot distribution